L Number	Hits	Search Text	DB	Time stamp
1	59903	Ion adj implant$5	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:19
2	6807	(Ion adj implant$5) and (target or process near2 chamber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:20
3	37	((Ion adj implant$5) and (target or process near2 chamber)) and (divided near2 chamber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:21
5	0	((((Ion adj implant$5) and (target or process near2 chamber)) and (divided near2 chamber)) and (ion near2 implant$5)) and (aperture near2 cahmber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:24
6	5	((((Ion adj implant$5) and (target or process near2 chamber)) and (divided near2 chamber)) and (ion near2 implant$5)) and (aperture near2 chamber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:24
4	37	(((Ion adj implant$5) and (target or process near2 chamber)) and (divided near2 chamber)) and (ion near2 implant$5)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:41
7	0	((((Ion adj implant$5) and (target or process near2 chamber)) and (divided near2 chamber)) and (ion near2 implant$5)) and (mass near2 analyzer)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:42
8	150	((Ion adj implant$5) and (target or process near2 chamber)) and (mass near2 analyzer)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:42
9	0	(((Ion adj implant$5) and (target or process near2 chamber)) and (mass near2 analyzer)) and (divided near2 chamber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:43
10	150	(((Ion adj implant$5) and (target or process near2 chamber)) and (mass near2 analyzer)) and (ion near2 implant$5)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:44
11	1	((((Ion adj implant$5) and (target or process near2 chamber)) and (mass near2 analyzer)) and (ion near2 implant$5)) and (accelerator near4 scanner)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:45
13	1	((((Ion adj implant$5) and (target or process near2 chamber)) and (mass near2 analyzer)) and (ion near2 implant$5)) and (scanner near4 ion?)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 10:45
12	18	((((Ion adj implant$5) and (target or process near2 chamber)) and (mass near2 analyzer)) and (ion near2 implant$5)) and (accelerator near4 ion?)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:19
14	6153	((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:21
15	1410	(((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.) and (target or process near2 chamber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:21
16	29980	((((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.) and (target or process near2 chamber)) (ion? near2 implant$5)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:22
17	13309	((((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.) and (target or process near2 chamber)) (divided near2 chamber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:23

18	1430	(((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.) and (target or process near2 chamber)) (accelerator near2 scanner)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:23
19	2051	(((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.) and (target or process near2 chamber)) (accelerator near4 ion?)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:24
20	1434	(((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.) and (target or process near2 chamber)) (scanner near4 ion?)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:25
21	10	((((250/492.21,492.3,309,310,) or (118/723,) or (438/14,15,800,) or (364/550,)).CCLS.) and (target or process near2 chamber)) (scanner near4 ion?)) and (aperture? near2 chamber)	USPAT; US-PGPUB; EPO; JPO	2003/08/20 11:25

10/050,743